# **Technical Information**

#### Simple and Easy Chemical Bond Analysis in XPS

## JPS-9000MC/SpecXPS: Photoelectron Spectrometer



External view of JPS-9000MC/SpecXPS X-ray photoelectron spectroscopy (XPS) is widely used for elemental analysis and chemical state analysis on the surface of metal, polymer, and semiconductor materials. Since XPS uses X-rays as an excitation source, samples are free from charge accumulation and are subject to a minimum of damage. This is one of the advantages over other surface analyzers. A new computer system for XPS has been developed to further enhance its performance. An outline of this new system is as follows.

#### **Features**

技術情報

- Windows<sup>®</sup> based MS-Windows<sup>®</sup> based system for global applications
- Menu driven easy operation
   Operation for data acquisition and processing is menu driven and easy to learn.
- Multiple windows
   Data processing tasks such as peak separation, quantitation, and data output are simultaneously performed during data acquisition.
- Acquired data can be processed by the integral software as well as a number of commercial application programs.
- Data transfer between programs
   Part or all of spectral data and windows can be copied, cut, and pasted to other programs, facilitating documentation of analysis.
- Connection to network The Ethernet interface is available as standard for easy networking with other instruments or computers.
- Auto analysis

Optional upgrade is available to enhance the speed and comfort of operation, including auto depth profiling, auto tilt analysis, multi point analysis, and multi sample analysis.

### An example of analysis

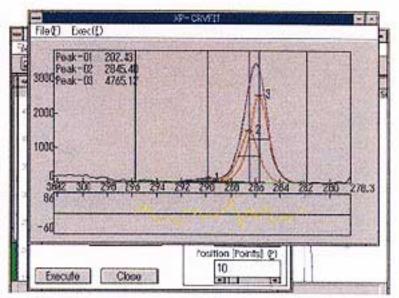
As a typical insulator, a piece of coated paper was analyzed. High quality paper is often coated with a layer of alumina or silica to increase the reflectance, providing a glossy surface on the paper. When developing this glossy film, a binder is applied to enhance the adhesion with the paper. A binder of a paper sample was analyzed in XPS to examine its physical properties. Figure 1 is the wide spectrum acquired. Elemental analysis on the surface detected impurities. Peak separation was applied to examine the bonding of carbon, a major component of the binder. Figure 2 shows the Peak Separation Control window, where the necessary parameters are entered. Figure 3 shows the calculated results. The C1s spectrum was separated into 3 peaks; peak-01 was C=O, peak-03 a CH bond, and peak-02 a modified C-O bond. The amount of peak-02 determined the adhesive power of the coating film. This example demonstrates that XPS is practical and effective in analyzing insulators.



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Wide Spectrum Acquisition Window

Peak Separation Control Window



C1s peak separation spectrum (sample: coated paper)

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